



INFORMATION DISCLOSURE STATEMENT BY APPLICANT

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Application Number 10/670,928
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First Named Inventor Chun-Li Liu et al.
Group Art Unit 2812
Examiner Name Unassigned
Attorney Docket Number SC12851ZP

U. S. PATENT DOCUMENTS

Examiner Initials*	Cite No. ¹	Document Number Number - Kind Code ² (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
DL	B1	5,534,713	07/09/1996	Ismail et al.	
	B2	5,846,857	12/08/1998	Ju	
	B3	5,943,565	08/24/1999	Ju	
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Examiner Initials*	Cite No. ¹	Foreign Patent Document Country Code ³ Number ⁴ Kind Code ² (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T ⁶
DL	B11	PCT - WO 02/45156 A2	06/06/2002	Armstrong et al.		

NON PATENT LITERATURE DOCUMENTS

Examiner Initials*	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²
DL	B12	Jung et al., "Implementation of Both High-Hole and Electron Mobility in Strained Si/SiGe on Relaxed Si _{1-x} Ge _x (x<y) Virtual Substrate," <i>IEEE Electron Device Letters</i> , Vol. 24, No. 7, July 2003, pp. 460-462.	
	B13	Tezuka et al., "Ultrathin Body SiGe-on-Insulator pMOSFETs with High-Mobility SiGe Surface Channels," <i>IEEE Transactions on Electron Devices</i> , Vol. 50, No. 5, May 2003, pp. 1328-1333.	

Examiner Signature	DL	Date Considered	4/2005
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